

Determination of Cr diffusivity in pure Ni and Ni-20Cr alloy

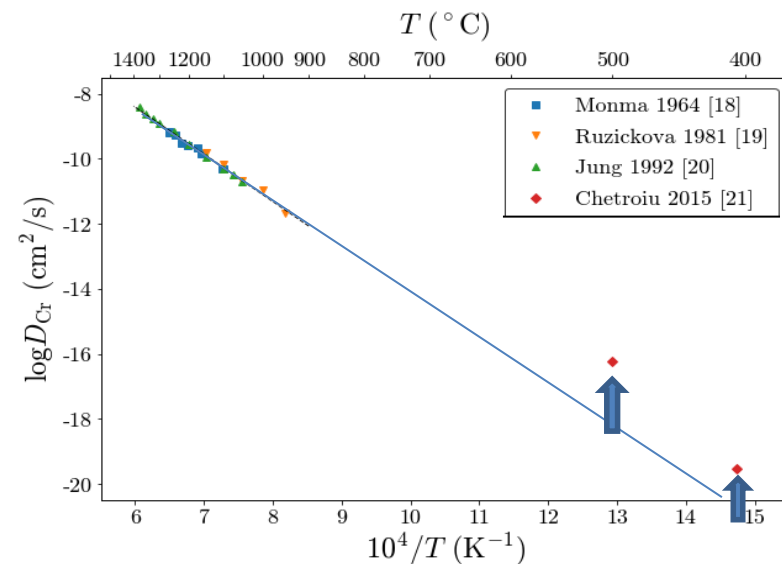
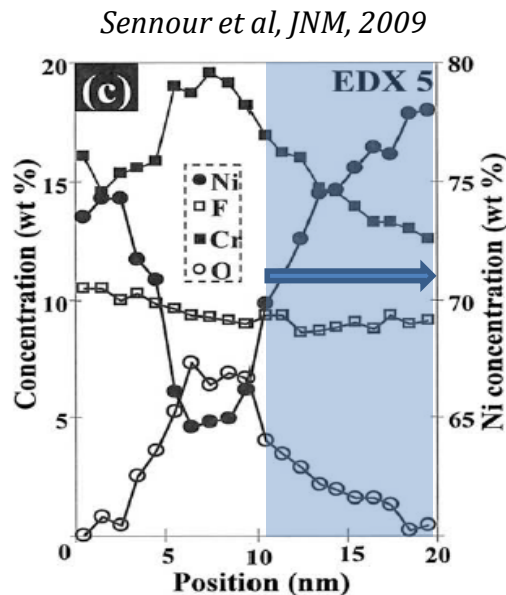
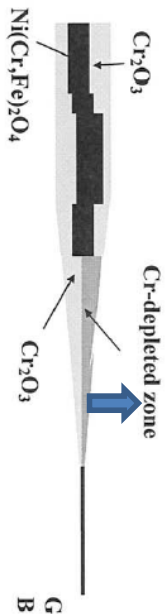
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→ 4.2 Characterisation of cold work effects on microstructure

Objective is to understand the Cr depletion depth observed at low temperatures in oxidized cracks formed by stress corrosion cracking in PWR: extrapolation made from high temperature measurements of Cr diffusivity cannot explain it. However if diffusion coefficients are higher at low temperature (as data obtained by Chetroui *et al*), the Cr depletion depth could be explained

→ **Need of Cr diffusion coefficient at low temperature**



1. In volume
 - Cr in Ni
 - ^{54}Cr in Ni-20Cr
2. In grain boundaries (Cr in Ni)
 - Annealed samples, regimes B and C
 - Rolled samples

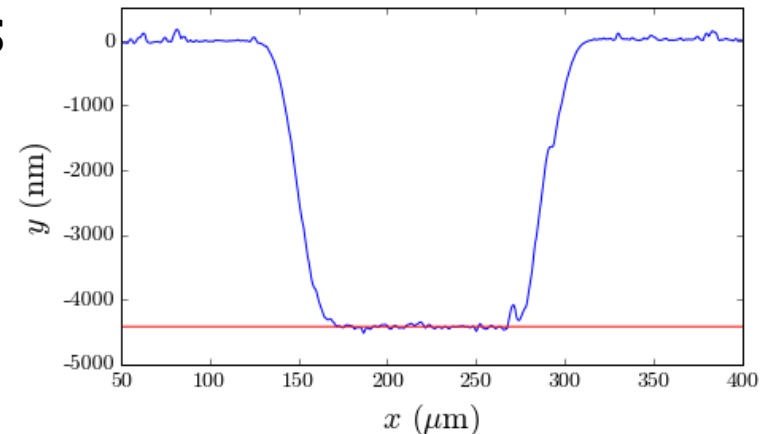
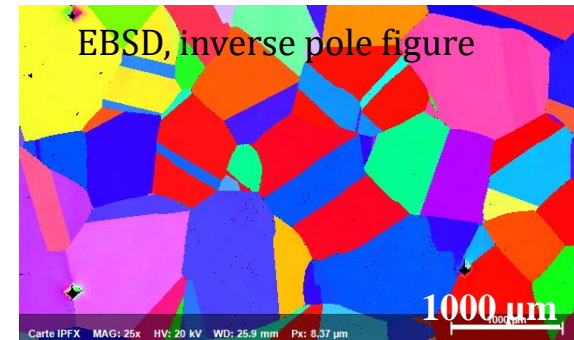
Experimental protocole:

- rolling-recrystallization of the substrat (Ni/Ni-20Cr)
- Mechanical grinding until 1 μm
- Thin deposit (5 nm) of natural Cr (for diffusion in pure Ni)/ ^{54}Cr (for diffusion in Ni-20Cr) by sublimation
- Ageing in glass ampoule under vaccuum, with Zr chips
- Concentration profile measured by SIMS
- Abrasion depth is then measured by contact profilometric method

Depth profile of a SIMS crater

SIMS Analyses : \varnothing 8-60 μm
→ measure performed within one grain or for one single grain boundary

Ni rolled-recrystallized

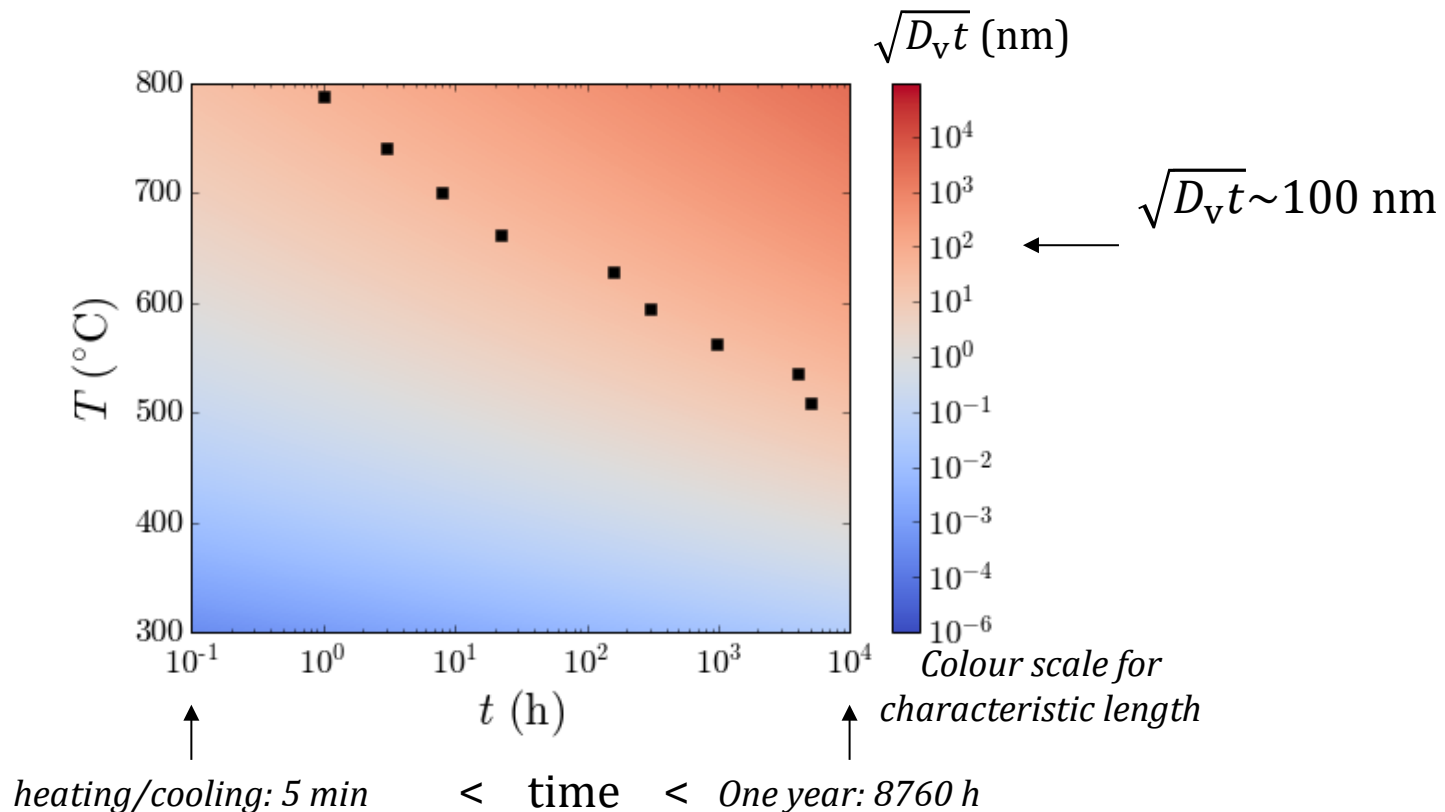


1. Volume diffusion: temperature / time conditions for ageing



Conditions:

- Characteristic diffusion depth > 100 nm small enough for having SIMS flat floor crater and deep enough for having enough points for good fit
- Ageing time has to be much higher (10 times) than the incompressible heating/cooling time (5 min) and reasonable (one year at maximum)



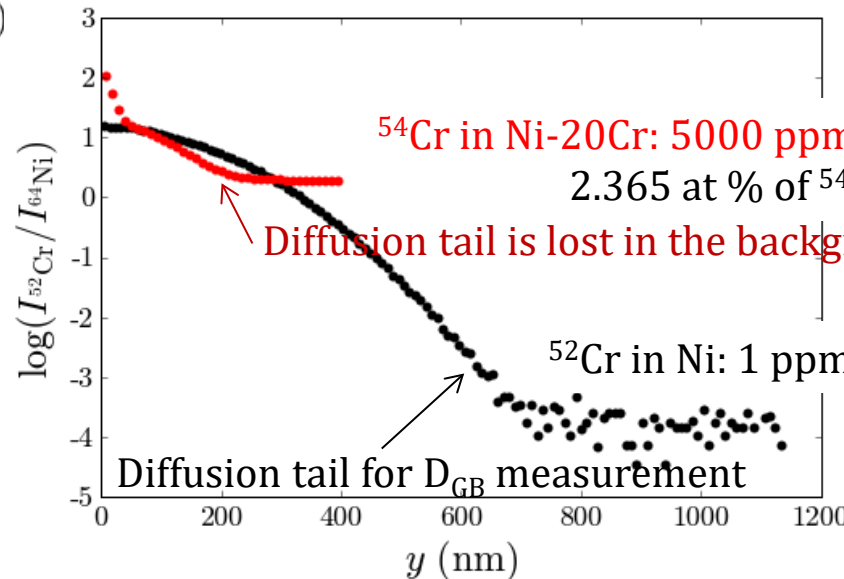
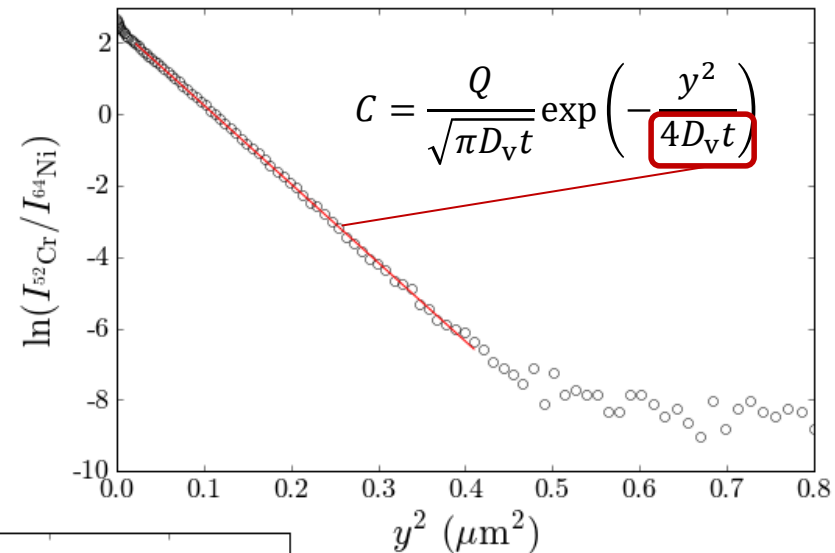
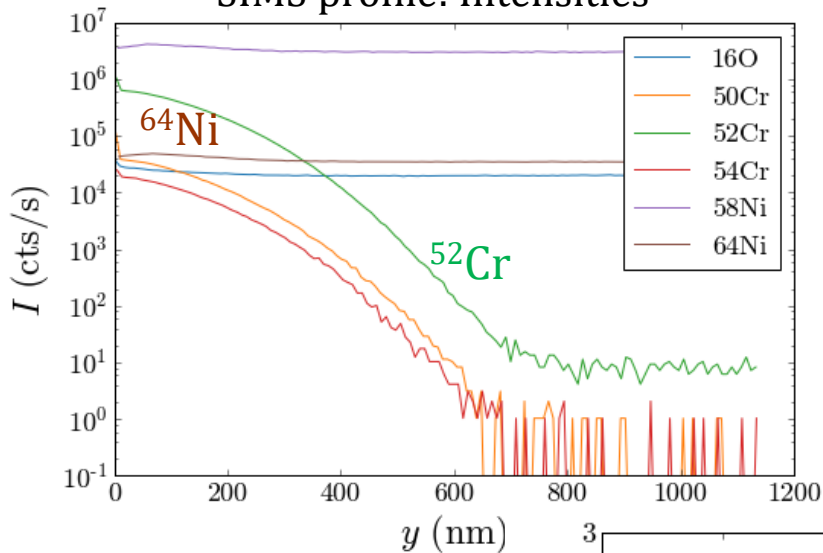
1. Volume diffusion: results treatments



Cr in Ni 162 h at 627 °C

Fit performed for $^{52}\text{Cr}/^{64}\text{Ni}$ vs. y^2

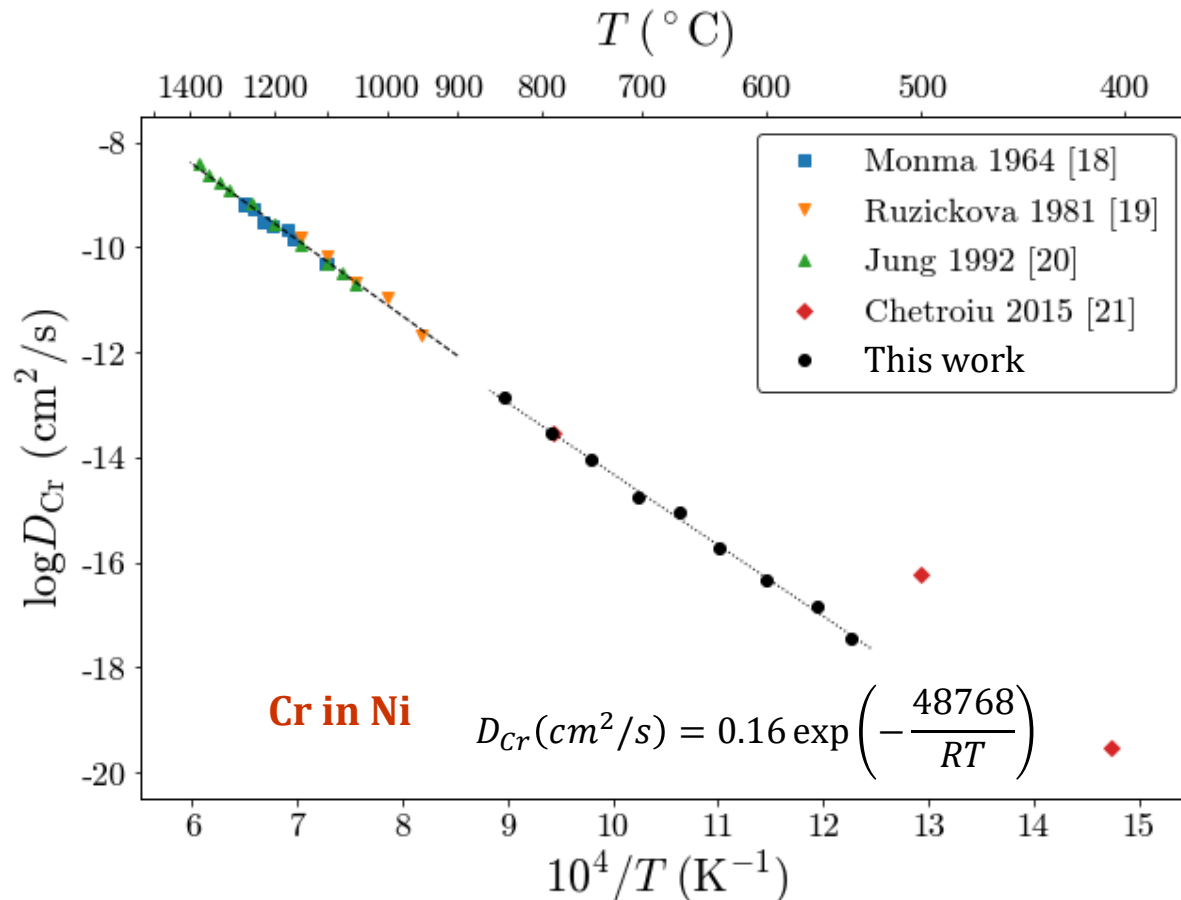
SIMS profile: Intensities



Substrat Ni vs. Ni-20Cr:

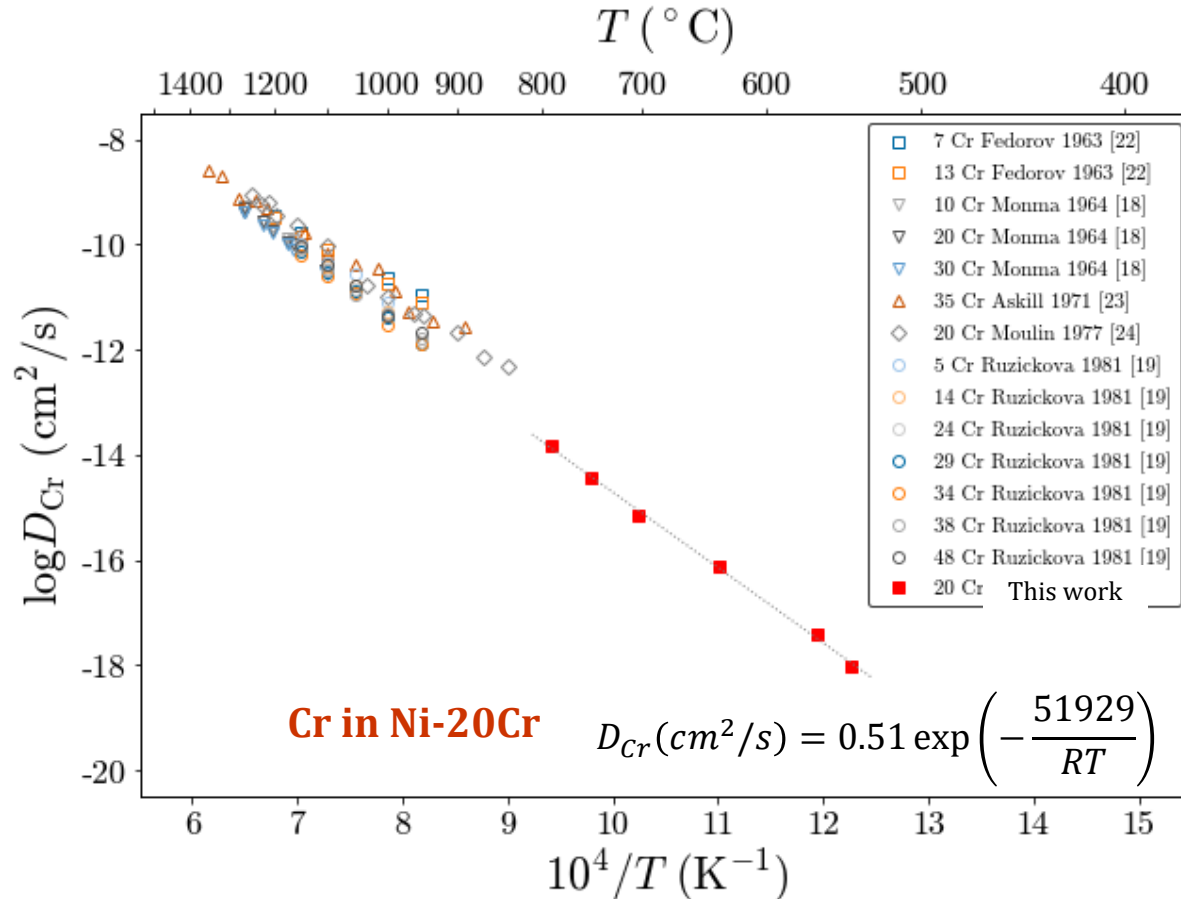
→ diffusion coefficient in GB cannot be measured in Ni-20Cr

1. Volume diffusion: results for Cr in Ni



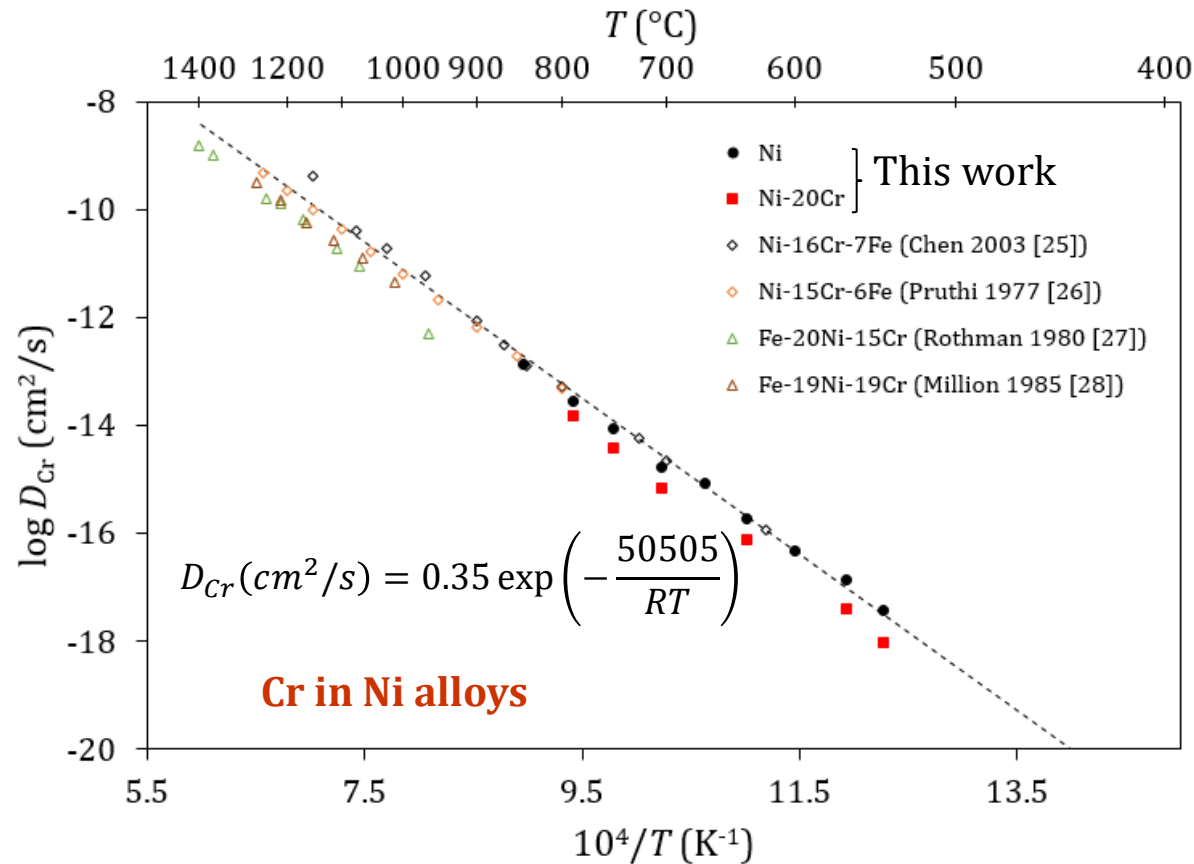
- Very good agreement with extrapolation at low temperatures of measurements made at high temperatures → no accelerated diffusion at low temperature
- These results cannot explain the higher Cr depletion depth observed during oxidation in PWR

1. Volume diffusion: results for Cr in Ni-20Cr



Very good agreement with extrapolation at low temperatures of measurements made at high temperatures

1. Volume diffusion: all data for Cr in Ni alloys and pure Ni

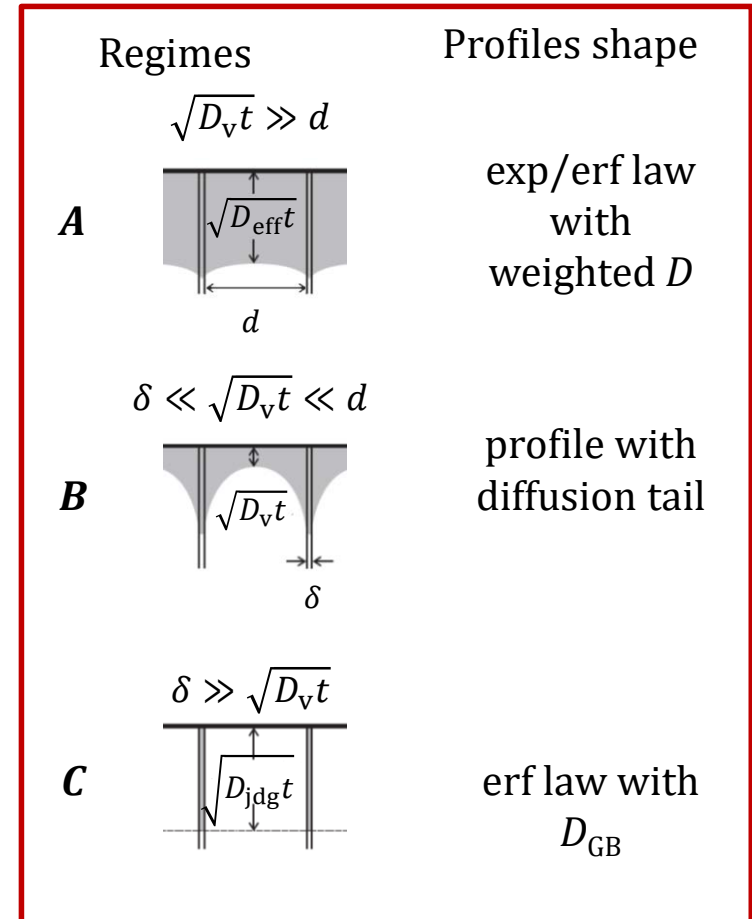
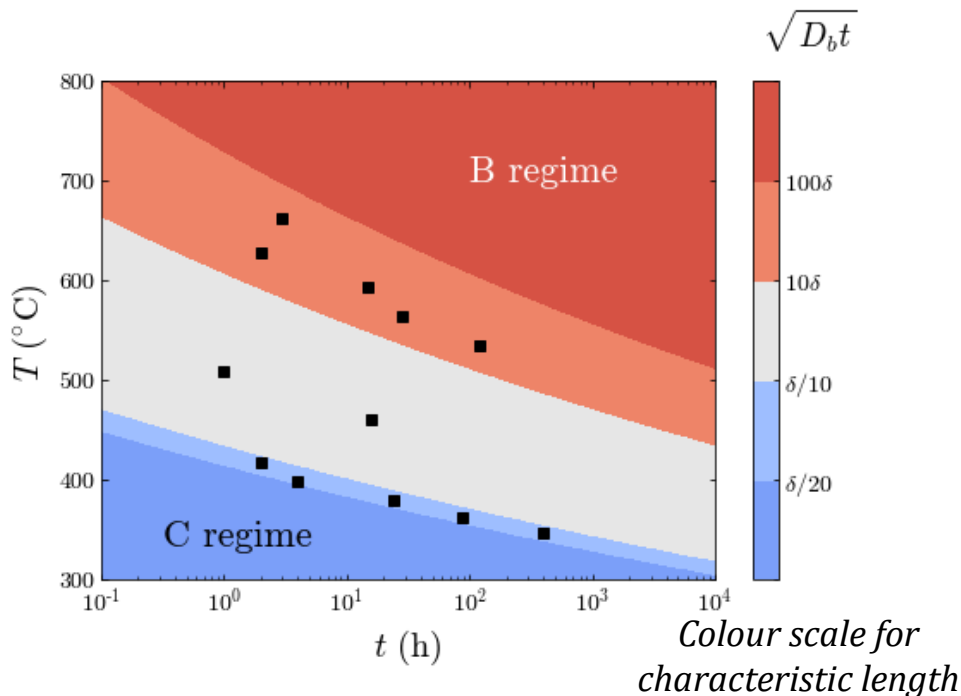
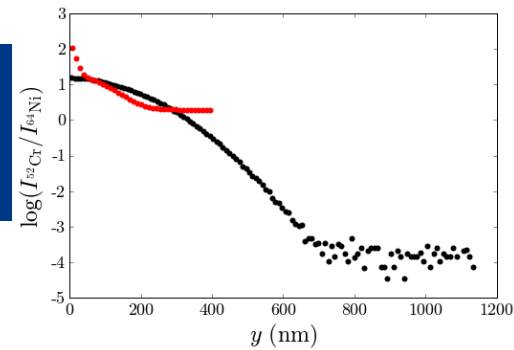


- Our results in agreement with data measured at high temperatures
- D_{Cr^*} is similar in Ni, Ni-Cr, Ni-Fe-Cr, Fe-Ni-Cr \rightarrow model alloys are good candidates for measurement of Cr diffusivities in FCC Ni-Fe-Cr alloys

2. Grain boundary diffusion: temperature / time conditions for ageing → only Cr in Ni

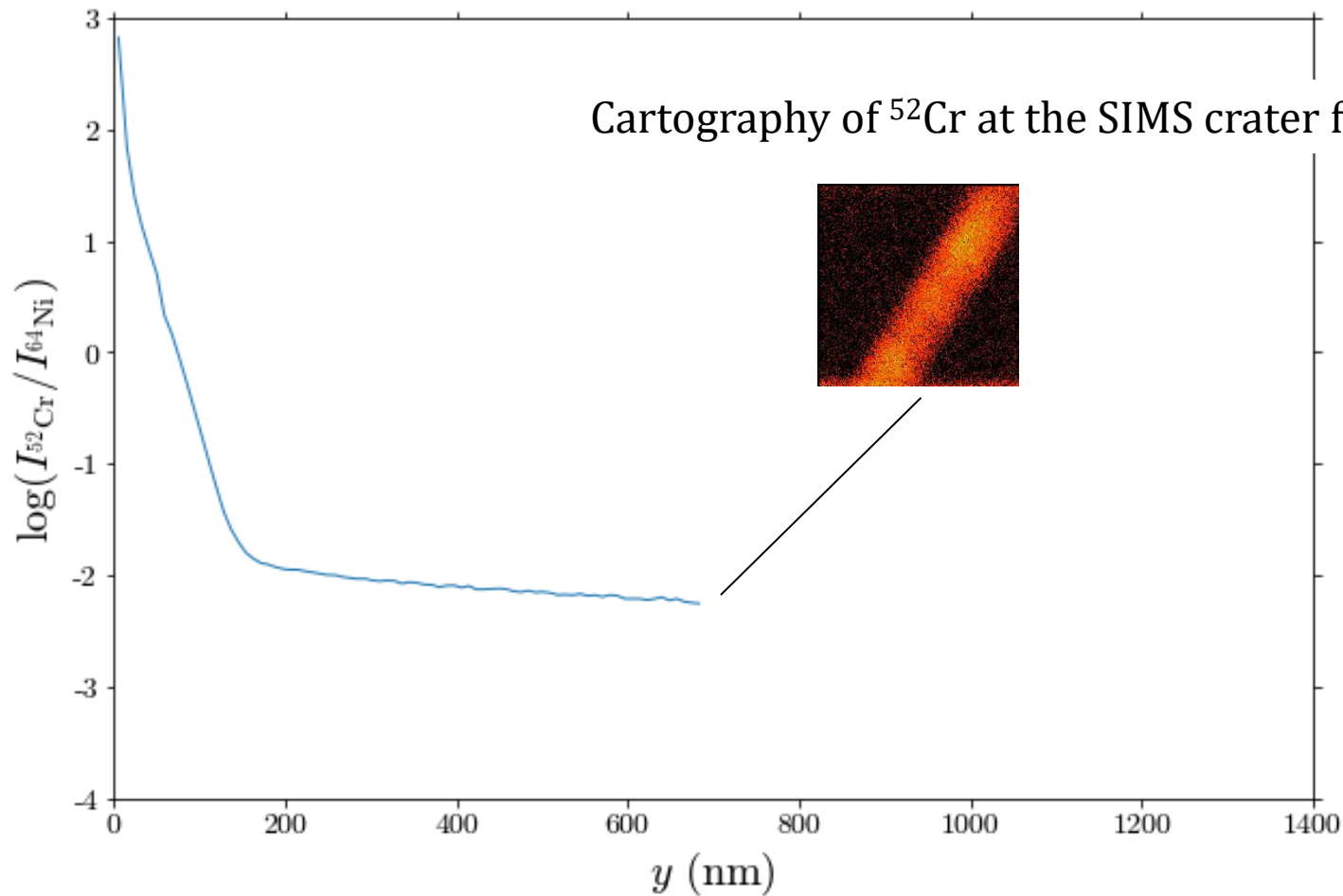
Conditions:

- For B regime $\delta < 10\sqrt{D_v t}$ and for C regime $\delta > 10\sqrt{D_v t}$
- Ageing time has to be much higher than the incompressible heating/cooling time (5 min)

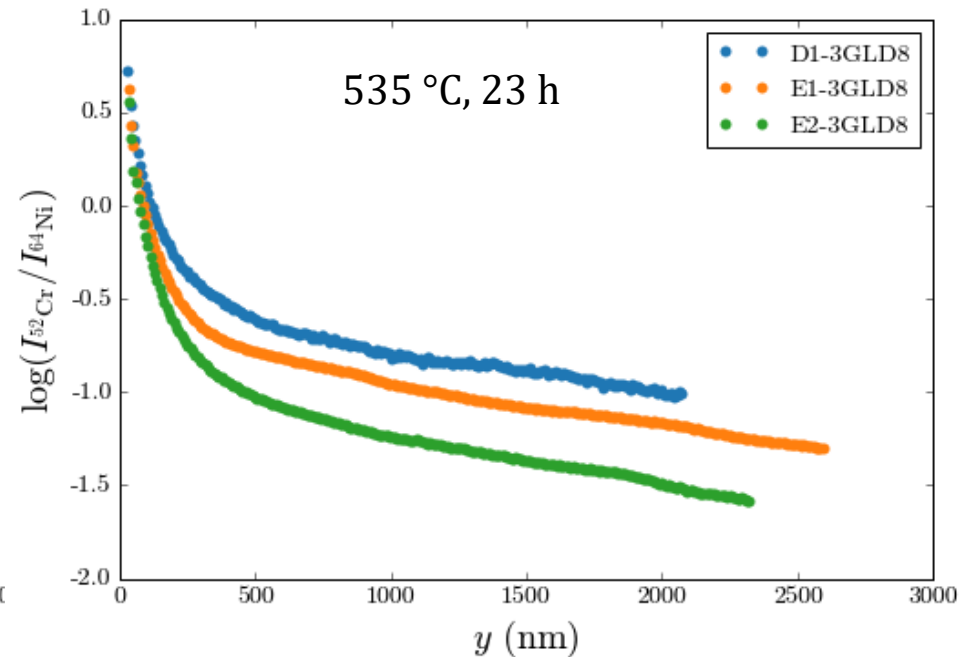
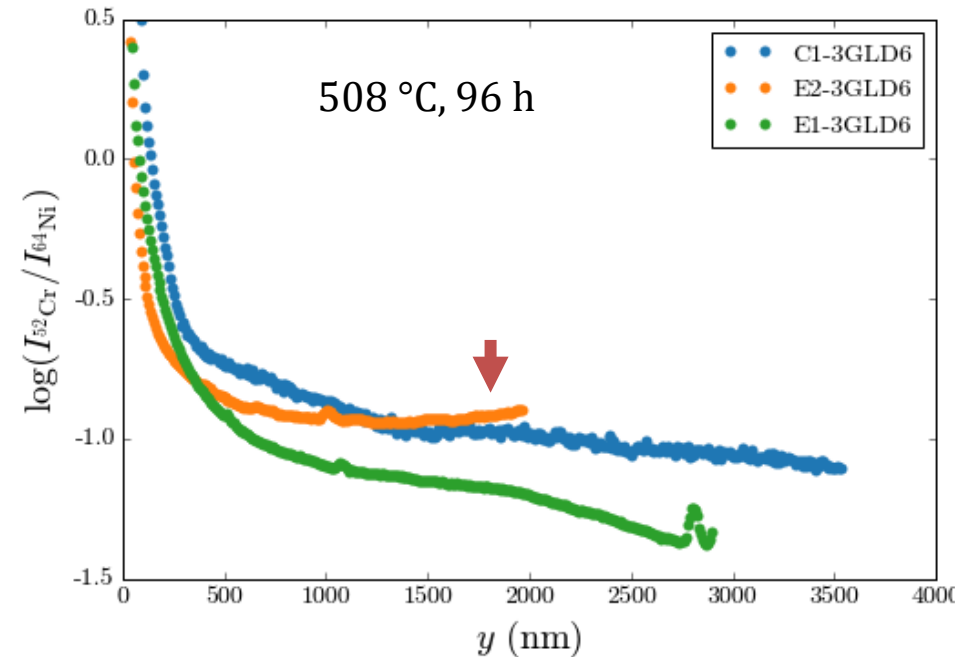


2. Grain boundary diffusion: Regime B SIMS profiles

Ageing: 28 h at 563 °C



2. Grain boundary diffusion: Regime B 90% rolled Ni

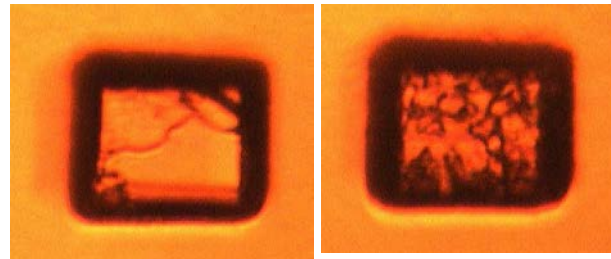


Profiles shape can be abnormal

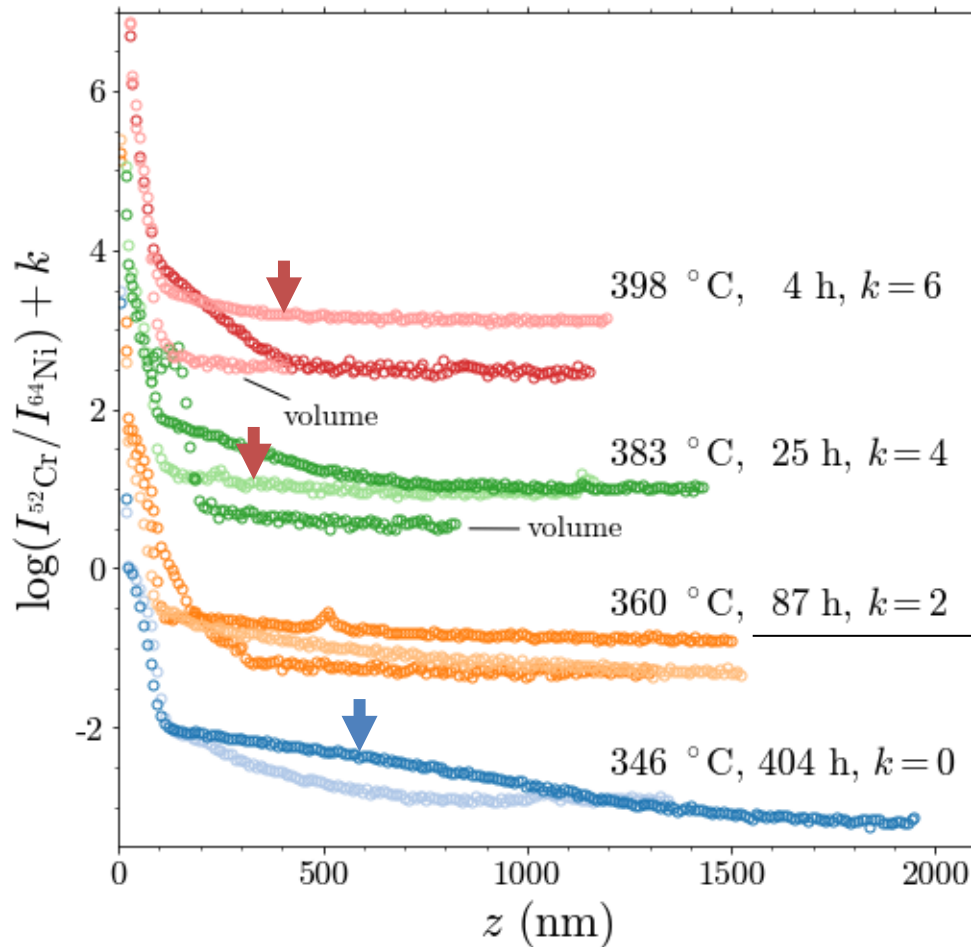
- Positive slope

During diffusion step → fast recrystallization

Optical image of the crater floor

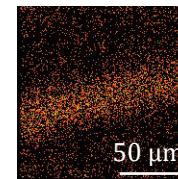


2. Grain boundary diffusion: Regime C SIMS profiles



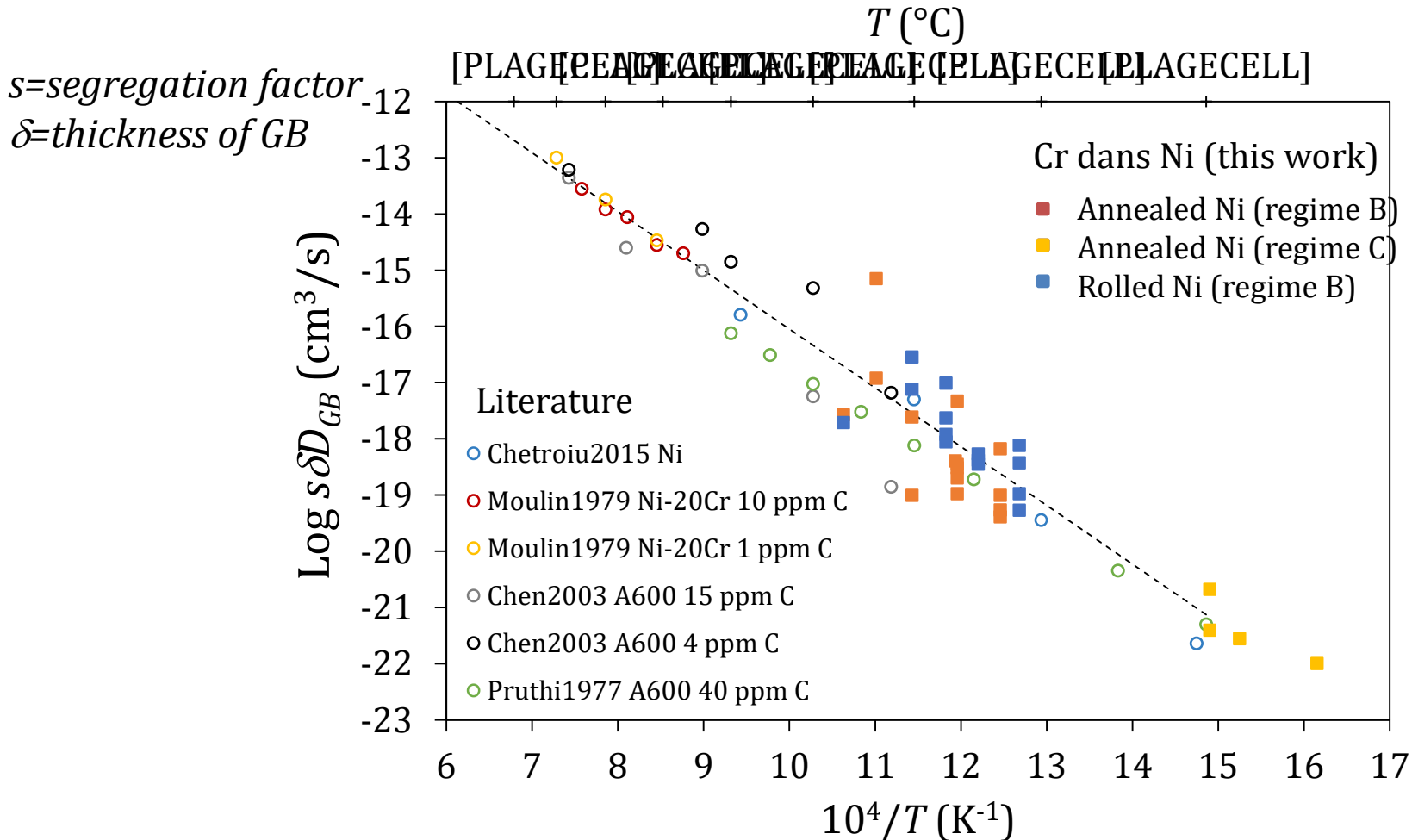
Profiles shape can be abnormal

- Convex shape of profile
- Flat profile



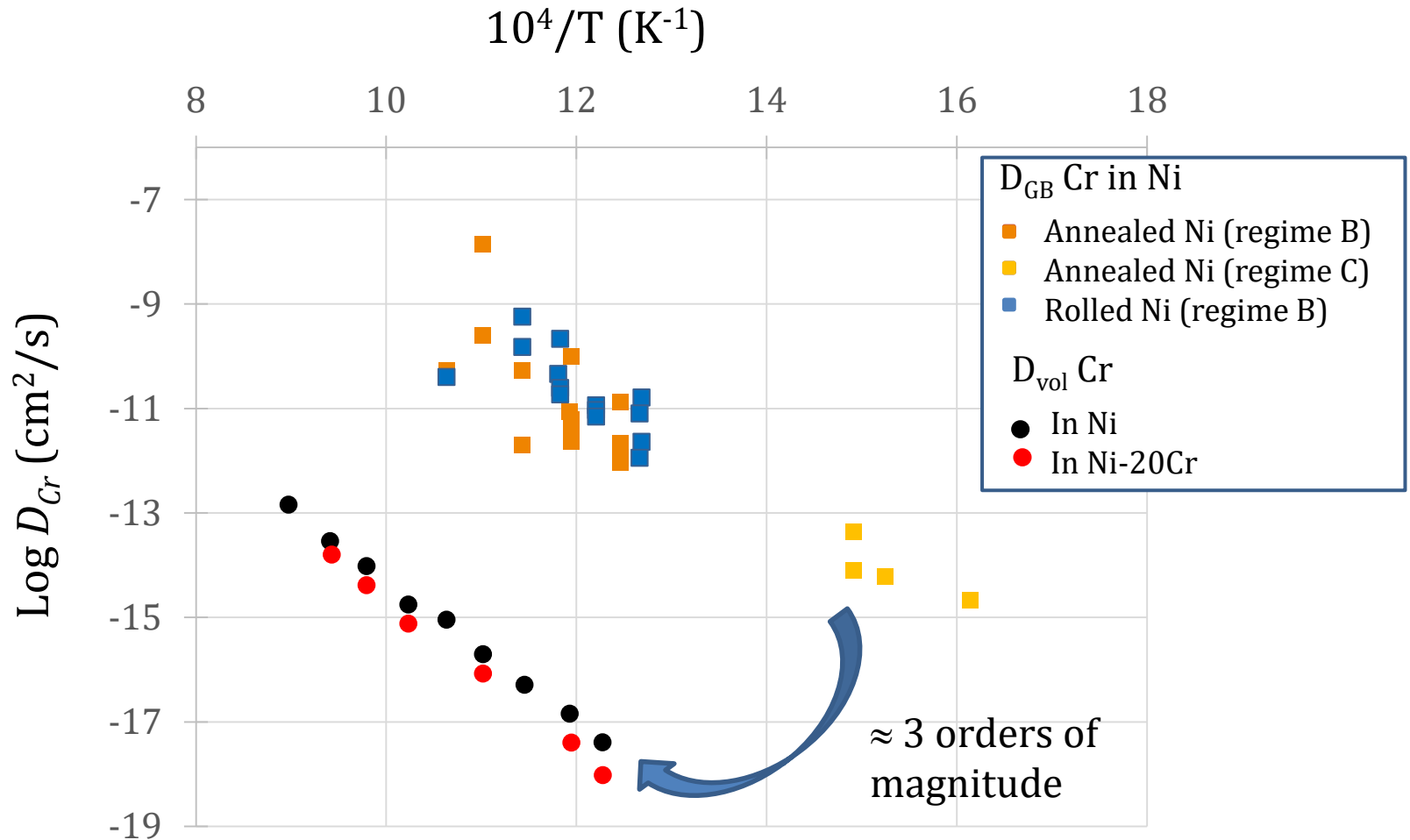
Equilibrium
segregation?

2. Grain boundary diffusion: all results



- Intergranular Diffusivity very scattered → due to various GB misorientation? Statistics could be done
- Trend in agreement with data obtained at high temperature
- No effect of cold-work & recrystallization on Cr diffusion

3. Summary



3 orders of magnitudes between diffusion in grain boundaries and in volume → order of magnitudes frequently obtained

4. Conclusions and prospects



Tracer Diffusion

In volume

- $D_{Cr^*}^{Ni}$ measured until 542 °C (versus 950 °C before)
- Q constant between 1400 and 542 °C
- Lower temperatures: need a surface cleaning before Cr deposit, and SIMS profile for very small depth (SIMS until 50 nm, Tomographic Atom Probe for lower?)
- D_{Cr^*} is very similar for Ni, Ni-Cr, Ni-Fe-Cr, Fe-Ni-Cr

In grain boundaries

- Measurements of $D_{Cr^*}^{Ni}$ performed until 346 °C
 - Very complicated
 - $D_{Cr^*}^{Ni-20Cr}$ impossible due to high level (2.365 at %) of ^{54}Cr within natural Cr
- Obtained results in agreement with data measured at high temperatures → no accelerated diffusion at low temperature
 - Cr diffusion is not increased in rolled samples → no accelerated diffusion due to cold-work

4. Conclusions and prospects



This study cannot explain the higher Cr depletion depth observed in oxidized cracks formed by stress corrosion cracking in PWR

- Is it due to combine effect of diffusion and stress?
→ Cr tracer diffusion coefficient could be measured under creep test (will be done in other project)
- Is it due to combine effect of diffusion and oxidation? Vacancies created in alloy by oxidation could accelerate the Cr diffusion
→ oxidation tests with sample of various microstructures are conducted in gas environments firstly and in PWR conditions secondly → **in progress**

The SOTERIA Consortium

